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[Continued on next page]

(54) Title: FABRICATION OF LOW DEFECTIVITY ELECTROCHROMIC DEVICES

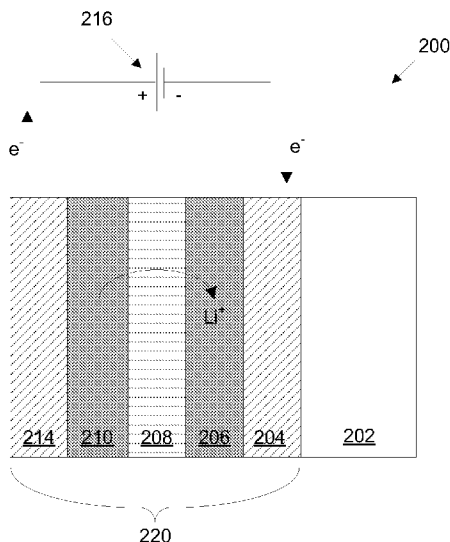


FIGURE 3

(57) Abstract: Prior electrochromic devices frequently suffer from high levels of defectivity. The defects may be manifest as pin holes or spots where the electrochromic transition is impaired. This is unacceptable for many applications such as electrochromic architectural glass. Improved electrochromic devices with low defectivity can be fabricated by depositing certain layered components of the electrochromic device in a single integrated deposition system. While these layers are being deposited and/or treated on a substrate, for example a glass window, the substrate never leaves a controlled ambient environment, for example a low pressure controlled atmosphere having very low levels of particles. These layers may be deposited using physical vapor deposition.



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**B. FIELDS SEARCHED**

Minimum documentation searched (classification system followed by classification symbols)

G02F 1/15; H01M 4/48; H01L 21/205; G02F 1/13; H01M 10/38

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched

Korean utility models and applications for utility models

Japanese utility models and applications for utility models

Electronic data base consulted during the international search (name of data base and, where practicable, search terms used)

eKOMPASS(KIPO internal) &amp; Keywords: electrochromic, window, counter electrode, ion conducting layer, integrated deposition system

**C. DOCUMENTS CONSIDERED TO BE RELEVANT**

Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
Y	WO 2009-029111 A1 (MIDWEST RESEARCH INSTITUTE et al.) See abstract; figure 1; part of "DETAILED DESCRIPTION"; claims 1-45	1-43
Y	KR 10-0874662 B1 (INTERNATIONAL MANUFACTURING & ENGINEERING SERVICES CO., LTD., KIDO JUNJI) See abstract; figures 1-2; paragraphs [0044]-[0075]; claims 1-27	1-43
Y	KR 10-2004-0057144 A (LG.PHILIPS LCD CO.,LTD.) See abstract; figures 2-4; pages 2-3; claims 1-6	1-43

 Further documents are listed in the continuation of Box C. See patent family annex.

\* Special categories of cited documents:

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**INTERNATIONAL SEARCH REPORT**

Information on patent family members

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Patent document cited in search report	Publication date	Patent family member(s)	Publication date
WO 2009-029111 A1	05.03.2009	None	
KR 10-0874662 B1	17.12.2008	EP 1260605 A1 JP 2002-348659 A US 2002-0179013 A1 US 2008-0299296 A1 US 7429300 B2 US 7785663 B2	27.11.2002 04.12.2002 05.12.2002 04.12.2008 30.09.2008 31.08.2010
KR 10-2004-0057144 A	02.07.2004	None	